	Application No.	Applicant(s)
M-4 PAH	10/699,075	ELLISON ET AL.
Notice of Allowability	Examiner	Art Unit
	Sikarl A. Witherspoon	1621
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to papers filed 31 October 2003.		
2. The allowed claim(s) is/are <u>1-19</u> .		
3. The drawings filed on are accepted by the Examiner.		
4.		
<ul> <li>Attachment(s)</li> <li>1. ☑ Notice of References Cited (PTO-892)</li> <li>2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 1/4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ul>	6. ☐ Interview Summary Paper No./Mail Dat 8), 7. ☐ Examiner's Amendn	ė

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## Allowable Subject Matter

The following is an examiner's statement of reasons for allowance: applicants claim a hydroformylation process comprising the reaction of at least one olefinic compound with hydrogen and carbon monoxide in the presence of a cobalt catalyst, and a method for suppressing the cobalt-catalyzed formation of methane from hydrogen and carbon monoxide in a hydroformylation process. It is recognized in the prior art, as shown by Oswald et al (US 4,593,141) that the synthesis gas, i.e., carbon monoxide and hydrogen, in hydroformylation reactions can contain un-reactive impurities such as water vapor, carbon dioxide, nitrogen, and methane formed during the reaction (see Oswald et al., col. 7, lines 3-7). The closest prior art of record fails to teach or fairly suggest conducting a hydroformylation reaction in a reactor comprising a gas cap region and a liquid-containing region, wherein a sulfur-containing additive is present on the inside walls of the gas cap region, as claimed herein. The presence of said sulfurcontaining additive on the inside walls of the hydroformylation reactor has been shown by applicants to suppress the methanation reaction, i.e., the formation of methane as a result of the hydroformylation reaction. Accordingly, the instant claims have been allowed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sikarl A. Witherspoon whose telephone number is 571-272-0649. The examiner can normally be reached on M-F 8:30-6:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Johann Richter can be reached on 571-272-0646. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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